

## SIMONA PVDF-NK and ECTFE-NK

New liner materials that meet the toughest requirements

GLOBAL THERMOPLASTIC SOLUTIONS

# The new high-performance backings for a wide range of applications

Used in composite structures and as cladding, SIMONA<sup>®</sup> liner materials made from fluoroplastics guarantee a high level of safety and reliability when storing and transporting chemically aggressive media. The backing provides a perfect mechanical bridge between the liner material and the supporting material that needs to be protected against corrosion.



The range of liner materials has now been expanded with the addition of SIMONA® PVDF-NK and SIMONA® ECTFE-NK. The new polyacrylonitrile (PAN) backing used here is particularly well-suited to composite structures that carry or transport acids thanks to its outstanding chemical resistance to the permeating chemicals hydrofluoric acid (HF) and hydrochloric acid (HCI). The new liner materials SIMONA® PVDF-NK and SIMONA® ECTFE-NK are the ideal complement to the range of polyester, glass and aramid backings currently in use.

Change in mass of the SIMONA NK backing following an immersion test in line with ISO 4433



#### What are polyacrylonitriles?

Polyacrylonitriles (or PANs for short) are semicrystalline polymers produced by the polymerisation of acrylonitrile. Their strong intermolecular interactions make polyacrylonitriles very tough and stiff as well as being resistant to most media plus light and heat.

The new liner materials are available in the standard dimensions for our PVDF and ECTFE semi-finished products. Customisations can be handled on request.

### GLOBAL THERMOPLASTIC SOLUTIONS

#### SIMONA AG

**Teichweg 16 55606 Kirn Germany** Phone +49(0)6752 14-0 Fax +49(0)6752 14-211 mail@simona.group.com www.simona.de



Contacts and more: simona.de/worldwide

Publication of this document renders all previous versions invalid. Any significant changes to this version will be published on our website www.simona.de. All the information in this flyer reflects our latest knowledge at the time of going to press. Errors and omissions excepted.